

# United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/709,596	05/17/2004	David B. Riggs	FIS920010074	3595
	7590 03/08/200 BURN LLP - IBM FI	EXAMINER		
55 GRIFFIN ROAD SOUTH			MARKOFF, ALEXANDER	
BLOOMFIELD	), CT 06002		ART UNIT	PAPER NUMBER
			1746	
SHORTENED STATUTORY	Y PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE	
3 MONTHS		03/08/2007	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

		Application No.	Applicant(s)			
Office Action Summary		10/709,596	RIGGS ET AL.			
		Examiner	Art Unit			
		Alexander Markoff	1746			
Period fo	The MAILING DATE of this communication apports reply	ears on the cover sheet with the c	orrespondence address			
WHIC - Exte after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DANSIONS of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. Operiod for reply is specified above, the maximum statutory period ware to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).			
Status						
1)🛛	Responsive to communication(s) filed on <u>07 D</u>	<u>ecember 2006</u> .				
2a)	This action is FINAL. 2b)⊠ This action is non-final.					
3)	☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
	closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	53 O.G. 213.			
Disposit	ion of Claims	•				
5)□ 6)⊠ 7)□	Claim(s) 1-4,6 and 7 is/are pending in the apple 4a) Of the above claim(s) is/are withdraw Claim(s) is/are allowed.  Claim(s) 1-4, 6 and 7 is/are rejected.  Claim(s) is/are objected to.  Claim(s) are subject to restriction and/or	vn from consideration.				
Applicati	ion Papers					
	The specification is objected to by the Examine	Г.	•			
· <u></u>	)) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.					
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
11)	Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Ex					
Priority ι	under 35 U.S.C. § 119					
a)	Acknowledgment is made of a claim for foreign  All b) Some * c) None of:  1. Certified copies of the priority documents  2. Certified copies of the priority documents  3. Copies of the certified copies of the priority documents  application from the International Bureau  See the attached detailed Office action for a list	s have been received. s have been received in Applicati ity documents have been receive I (PCT Rule 17.2(a)).	on No ed in this National Stage			
Attachmen	t(s)					
2) 🔲 Notic 3) 🔲 Inform	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO/SB/08) r No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:	ate			

Application/Control Number: 10/709,596

Art Unit: 1746

#### **DETAILED ACTION**

#### Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 12/07/06 has been entered.

## Claim Rejections - 35 USC § 112

- 2. The following is a quotation of the first paragraph of 35 U.S.C. 112:
  - The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.
- 3. Claims 1-4, 6 and 7 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention.

The applicants amended the claims to recite that the step of coating of the material with the claimed solvents is conducted subsequent to implantation of dopant ions and prior to any other semiconductor manufacturing process.

The original disclosure fails to support the limitation of conducting the coating step prior to any other semiconductor manufacturing process.

## Claim Rejections - 35 USC § 102

4. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 5. Claims 1, 4 and 7 are rejected under 35 U.S.C. 102(b) as being anticipated by Chang et al (US Patent No 4,144,634).

Chang et al teach that methods of cleaning substrates with dopant ions with solvents as claimed were known in the art. Chang et al also teach heating the substrates. See entire document, especially column 5, line 41-44 and column 6, lines 5-10.

6. Claims 1, 4, 6 and 7 are rejected under 35 U.S.C. 102(e) as being anticipated by Giedd (US Patent No 6,489,616).

Giedd teaches a method as claimed. See entire document especially column 15, line 65 – column 16, line 11. Giedd states that removing dopant ions with the claimed solvents was conventional in the art (column 16, lines 6-11).

## Claim Rejections - 35 USC § 103

- 7. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Application/Control Number: 10/709,596

Art Unit: 1746

- 8. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 9. The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:
  - 1. Determining the scope and contents of the prior art.
  - 2. Ascertaining the differences between the prior art and the claims at issue.
  - 3. Resolving the level of ordinary skill in the pertinent art.
  - 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.
- 10. Claim 3 is rejected under 35 U.S.C. 103(a) as being unpatentable over any one of Chang and Giedd.

Chang and Giedd teach the claimed method except for specific recitation of rinsing the substrate with water.

However, it is notoriously well-known that rinsing substrate with water is a conventional step of a conventional semiconductor manufacturing process, which is conducted after any liquid chemical processing of after a CMP process it would have been obvious to an ordinary artisan at the time the invention was made that at least at

Application/Control Number: 10/709,596

Art Unit: 1746

some point of manufacturing of the devices of Chang and Giedd the substrates would be rinse with water.

11. Claims 1-4, 6 and 7 are rejected under 35 U.S.C. 103(a) as being unpatentable over the state of the prior art admitted by the applicants in view of Giedd.

The applicants admitted in the specification that it was known in the art that control of the dopant ions is critical for the device performance and that diffusion of the ions into undesired areas can damage the device (part [0008]). The applicants further admitted that conventional cleaning methods conducted at different stages of the manufacturing comprise heating and rinsing the substrates (parts [0009-0013]).

Giedd teaches that removing dopant ions with the solvents as claimed was conventional in the art (column 16, lines 6-11).

It would have been obvious to an ordinary artisan at the time the invention was made to utilize cleaning of dopant ions disclosed by Giedd as conventional for it's conventional purpose to remove dopant ions from undesired areas in the prior processes disclosed by the admitted prioer art with reasonable expectation of success in order to prevent damage of the devices by the ions in undesired areas.

### Response to Arguments

12. Applicant's arguments with respect to amended claims have been considered but are most in view of the new ground(s) of rejection.

The applicants amended the claims and argue that the previously applied rejections are not proper.

The amended claims are addressed in the rejections above.

Application/Control Number: 10/709,596 Page 6

Art Unit: 1746

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Alexander Markoff whose telephone number is 571-272-1304. The examiner can normally be reached on Monday-Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Barr can be reached on 571-272-1414. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Alexander Markoff Primary Examiner Art Unit 1746

AM

ALEXANDER MARKOFF
PROMABY EXAMINER